

Attorney Docket No.: 1384-1023

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application: John L. Pierce  
Serial No.: 09/738,193  
Filed: December 15, 2000  
Art Unit: 2827  
Examiner: David E. Graybill  
For: Method for Producing a Semiconductor Wafer-  
Interposer

Mail Stop Non-Fee Amendment  
Commissioner of Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Declaration Under 37 C.F.R. §1.131

Dear Sir:

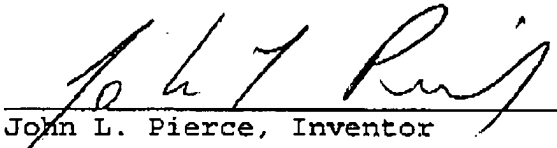
This is a Declaration under 37 C.F.R. §1.131 to establish invention of the subject matter of the above-captioned application in the United States at a date prior to November 9, 2000, i.e., the effective date of the cited prior art United States Patent No. 6,400,019, entitled "Semiconductor Device with Wiring Substrate," issued in the names of Hirashima et al., (hereinafter "Hirashima").

To establish the date of invention of the subject matter of the above-captioned application, a copy of a disclosure form entitled "Method for Constructing a Wafer Interposer by Using a

B-Stage Laminates" and a copy of a disclosure document entitled "Method for Constructing a Wafer Interposer by Using a B-Stage Laminates" are attached hereto and submitted as evidence as Exhibit A and Exhibit B, respectively. Based on these documents, it can be seen that the invention in this application was made at least by the date of September 14, 2000, which is a date earlier than the effective date of the reference.

As the below named inventor, I hereby declare that the completion of the invention was diligent, from the time of my conception, to a time just prior to the date of Hirashima, up to the filing of this application on December 15, 2000.

I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code, and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

  
John L. Pierce, Inventor

March 10, 2004  
Date

# EXHIBIT A

## INVENTION DISCLOSURE RM

(Please print or type)

1. Descriptive title of the invention: METHOD FOR CONSTRUCTING A  
WAFER INTERPOSER BY USING B-STAGE LAMINATES

2. Invention submitted by:

(a) Name JOHN PIERCE  
first middle last  
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(b) Name \_\_\_\_\_  
first middle last  
Employee # \_\_\_\_\_ Department \_\_\_\_\_ Group \_\_\_\_\_  
Employment Status: ☐ Employee ☐ Subcontractor  
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Phone \_\_\_\_\_ Fax \_\_\_\_\_ E-mail \_\_\_\_\_  
Home: Address \_\_\_\_\_  
Phone \_\_\_\_\_ Fax \_\_\_\_\_  
Country of citizenship \_\_\_\_\_  
Supervisor \_\_\_\_\_  
name location phone number

(If there are more than two inventors, please include additional sheets so that the above information is provided for all inventors)

3. History of invention  
Date and location invention was first conceived 9/1/00 TIDC  
Date first sketch or drawing was made 9/1/00 ☐ Not yet started  
Date construction or model was started ☒ Not yet started  
Date construction or model was completed ☒ Not yet complete  
Date testing was started ☐ Not yet started  
Date successful testing was completed ☒ Not yet complete
4. Was any of the work performed under or in preparation of a government contract? ☐ Yes ☒ No
5. Has there been any experimental use of the invention? ☐ Yes ☒ No

CONFIDENTIAL AND PRIVILEGED INFORMATION WHEN COMPLETED

-1-

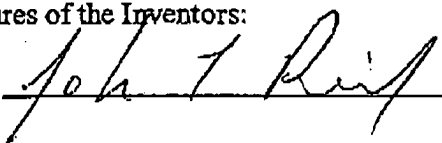
- Has there been any effort to sell, sale or production use of the invention? ☐ Yes ☒ No  
Is sale or production use presently scheduled? ☐ Yes ☒ No  
If any answers are "yes," please explain giving dates and circumstances \_\_\_\_\_

6. (a) Has there been any disclosure of the subject matter of this invention outside the company or is such disclosure anticipated? ☐ Yes ☒ No
- (b) Has the subject matter of this invention been included in any publication, such as catalogs, advertising materials, data books, application notes, conference papers, magazine articles, government or customer proposals, or is any such disclosure anticipated? ☐ Yes ☒ No  
If your answer was Ayes, please explain giving dates and details of publication \_\_\_\_\_

7. Please provide a brief written summary of the invention and attach any sketches, diagrams, drawings, prints, photographs, etc. which will aid in understanding this invention. Each of the points set forth below should be included in the written description:

- (a) A brief discussion of the problem(s) solved by the present invention.  
(b) A list and discussion of known prior art, including the manner in which others have attempted to solve the problem(s) and the disadvantages and weaknesses in the prior art solutions. (Specify any literature references or patents available.)  
(c) A specific embodiment of the invention including the important features of the invention believed to be novel along with the advantages of the invention over the prior art solutions.

8. Signatures of the Inventors:

(a)  Date SEPT 14, 2000  
(b) \_\_\_\_\_ Date \_\_\_\_\_

9. Signatures of the Witnesses:

We, the undersigned, have read and understood this disclosure:

Name (typed or printed)	Signature	Date
_____	_____	_____
Name (typed or printed)	Signature	Date

CONFIDENTIAL AND PRIVILEGED INFORMATION WHEN COMPLETED

# EXHIBIT B

**METHOD FOR CONSTRUCTING**  
**A WAFER INTERPOSER**  
**BY USING B-STAGE LAMINATES**

**JOHN PIERCE**

**September 14, 2000**

## **BACKGROUND:**

Previous disclosures have described techniques for building a wafer interposer. These disclosures have also provided information regarding the cost and performance advantages of a wafer interposer as contrasted to traditional semiconductor backend packaging practices. Each of the previously disclosed inventions described a substrate that is connected to a wafer to form a wafer interposer. Implementing a wafer in this fashion requires that the substrate be very coplanar (flat).

Because of the very precise and costly manufacturing methods used to create a semiconductor wafer, it can, for all practical purposes, be considered to be flat. Typical substrate materials, however, are much less coplanar. A laminate substrate may have variances up to .005 in./in. A total variance of .04 inch could be expected across an 8 inch wafer. If the substrate is connected to the wafer using solder, then this solder connection would be required to compensate for the height variances in the substrate. Because of the geometries of the pads on the wafers, a maximum solder ball height of approximately .01 inch is possible. Therefore, only those solder bumps that resided on the highest part of the substrate would make contact with the wafer.

In the above example, the coplanarity of the substrate would have to be less than .00125 in./in. (.01 in across 8 inches) in order for all pads of the wafer to be contacted by the substrate. This requirement increases the cost of the substrate. As geometries become tighter, solder bump height decreases. Wafers are also becoming larger (e.g. 300mm = 12 inches across). These two factors increase the coplanarity or flatness requirements of the substrate which increases the cost of the substrate.

The invention described here overcomes the coplanarity problem by building the interposer onto the wafer. The substrate material is malleable at the time that it is placed on the wafer. Therefore, it can be urged against all contact pads on the wafer. Later, the entire assembly is cured. During the cure process solder contacts are made. Additionally, the underfill used to stabilize the assembly is cured at this time.



## **DESCRIPTION OF THE INVENTION:**

Figure 1 shows the topside of a substrate 10. There are contact pads on both sides of the substrate. The pads that will contact the wafer are on the bottom and are not shown in Figure 1. These pads on the bottom are arranged to be in a mirror image of the pads on the wafer. They will typically have smaller geometries and tighter pitches than the pads shown on the top.

Figure 1 shows contact pads 11 that connect to four individual circuits 12 or die on the wafer. Each die has nine pads. Each contact pad on the bottom of the substrate 10 is connected to a pad 11 on the topside of the substrate. Although Figure 1 shows a die with nine pads, an actual semiconductor die may have many more individual contact pads (as many as 2000 or more). The pads 11 on the topside are constructed in an array with geometries larger than the pads on the bottom. This is done to enable easy contact with external burn-in or electrical test equipment. It also allows the use of less expensive printed circuit boards for attachment of individual circuits after the circuits have been fully processed and diced.

It is important to note that the substrate of Figure 1 has not been attached to the wafer. The material of the substrate is a laminate containing partially cured resins. This is often referred to as "B stage" laminate. The conducting pads on the top and bottom of the substrate can be copper, gold or other suitable conductive metal. They can also be a compound of different metals.

Figure 2 shows a wafer prepared for connection to the substrate. Solder bumps 21 have been applied to wafer 20. There will be one unique solder bump for each contact pad on the wafer. The solder bump may be applied directly to the die contact pad. Often the die pad will require additional layers of metal to be applied prior to the application of the solder bump. ~~This is necessary to insure that the solder bump makes a strong and reliable connection to the die pad.~~

Additional metalization may be added to the wafer prior to the application of the solder bumps that redistribute the die contact pads. This is often necessary if the die pads have very small geometries or very close pitches. The redistributed pads help ensure that the solder connections made between the wafer and the substrate are robust and reliable.

Also shown in Figure 2 is no flow underfill 22. The purpose of this underfill is to stabilize the assembly by resisting any lateral forces caused by the differences between thermal expansion of the wafer and the substrate. The underfill is applied over the entire wafer but is not cured.

Figure 3 shows the substrate and the wafer prior to assembly into a wafer interposer. At this point the substrate 10 still contains partially cured resins. The solder bumps 21 have been applied to the contact pads of each die on wafer 20. The no flow underfill 22 is not cured at this step.

Prior to assembly, the wafer 20 is placed on a flat surface 31. The wafer is held in place by vacuum or other suitable technique. The substrate 10 is also held in place against a flat surface 32. A suitable compound is used to coat the surface of the substrate 10 that is in contact with the flat surface 32. This prevents the substrate from adhering to the flat surface during the curing process. Flat surfaces 31 and 32 as illustrated in Figure 3 can be various configurations and materials. The primary requirement of the surface is that it is as coplanar as the wafer. Also, not shown is a mechanism that can bring the surfaces together. This mechanism will be obvious to those skilled in the art. The mechanism must be able to adjust the position of the substrate or the wafer in order to perfectly align the contact pads on the substrate 10 with the solder bumps 21 on the wafer 20. Alignment is accomplished using split vision optics or any other suitable technique.

Prior to final assembly, the flat surface 32 may be heated to insure that the substrate 10 is in a malleable condition. The heating can be accomplished using forced heated air, heating coils or other method generally known in the industry.

Figure 4 shows the interposer assembly during assembly. Flat surfaces 32 and 31 are brought together by mechanical mechanisms not shown such that all solder bumps 21 contact the pads on substrate 10. A method for insuring that 100% contact is made is to compress the solder bumps. For example, if the solder bump is nominally .006 in. high, then the surfaces would be brought together such that the resulting solder bump would only be .005 in. high. This would compensate for any and all variances in the coplanarity of the substrate, wafer, solder bumps and flat surfaces.

Another method of manufacture includes applying underfill and solder bumps to the substrate instead of the wafer. Additionally, underfill and solder bumps may be applied to both the wafer and the substrate. The particular geometries of the contact pads or characteristics of the wafer or substrate would dictate the preferred method.

Figure 5 shows a "before" and "after" example of the effect of compression to make 100% connection. Before compression takes place, solder bumps 50a and 50b are not making contact with substrate 10. If the entire assembly were cured at this stage, missing connections would be present. Bringing the flat surfaces closer together results in the "after" configuration in Figure 5. Here, solder bumps 50a and 50b are making contact with substrate 10. The other solder bumps are compressed to allow 50a and 50b to contact the substrate. As they are compressed, solder must expand as height is reduced. This is possible because the surrounding underfill is not yet cured. The amount of compression to be applied will vary with each individual application.

After the wafer and substrate are properly joined, the entire assembly is cured. This curing can take place while the assembly continues to be held by the flat surfaces. Alternatively, the wafer and substrate may be removed from the surfaces and cured. During the curing process, the substrate and underfill become fully cured. In addition, the solder bumps make permanent contact with the contact pads. After the curing process, testing, burn-in or other processes designed to determine the merit of each circuit may be performed. The last step is dicing the assembly into individual circuits.

The invention described uses solder as a method of achieving connection. Other materials such as conductive polymer, conductive plastic or other suitable conductive material may be used.

The interposer may also be constructed by adding additional layers of substrate. This may be necessary to achieve thicker packages or to add additional interconnect options such as power and ground planes.